

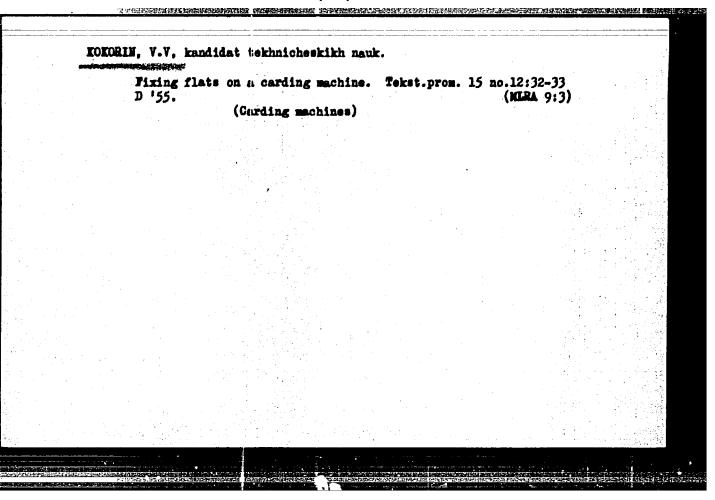
KOKORIH, Vasiliy Vasilihevich; SOKOLOVA, V.Ye, redaktor; KLIKIA, B.M.

[Installation, assembly, repair and adjustment of cotton ring spinning machines] Ustroistvo, montanh, remont i naladka kolitse-priadilinyth mashin khlopchatohumashnoi promyshlennosti. Moskva.

Gos.mauchno-tekhnind-vo Miniuterstva promyshletovarov shirokogo potrebleniia SSSR, 1955. 156 p.

(Spinning-machinery)

(MLRA 8:8)



Hew method of spinning. Tekst. prom. 16 no.8:68 Ag '56.
(MLRA 9:10)
(Spinning)

CONTROL OF THE PROPERTY OF THE

SVYATOSLAVOV, Nikolay Ivanovich, kand.tekhn.nauk; RHLYAYEV, Boris Alekseyevich; KOKORIN, V.V., retsensent; KRYUKOV, V.M., spetsred.; OHLOVA, L.A., red.; KNAKNIN, M.T., tekhn.red.

[Cotton opening and picking equipment] Rasrykhlitel'no-trepal'nyi agregat dlia khlopka. Moskva, Cos.nauchno-tekhn.isd-vo lit-ry po legkoi promyshl., 1959. 130 p. (NIRA 13:3)

1. Glavnyy konstruktor savoda Kustekstil'mash.(for Belyayev). (Cotton machinery)

## KOKORIN. V.v. Mew method of opening cotton. Isv. vys. ucheb. sav.; tekh. tekst. prom. no.3:76-80 '59. (MRA 12:11) 1. Vsesoyusny; saochnyy institut tekstil'noy i legkoy promyshlennosti. (Cotton manufacture)

APPROVED FOR RELEASE: 06/19/2000 CIA-RDP86-00513R000723710010-0"

35906-66 EHT(m)/ ACC NR: AP6007360	I/EWP(1)/EII IJP(c)	JD/HW/JG SOURCE CODE: 1	IR/0126/66/021/00	2/0311/0314
	. V.; Chuistov, K. V.			72
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Card 1/2			unc: 51	18.41548.73

### KOKORIN, Ye.V.

Using amplitude curves of reversed microseismic logging for the selection of the optimal conditions for excitation. Razved. geofix. no.5427-29 165. (MIRA 18:9)

£7809

S/070/60/005/006/009/009 E201/E391

9.4310 (3203, 1143, 1160)

AUTHOR:

Valeraim Vo Vu

Kokorin, Ye.Yu.

TITLE: Use of the Peltier Effect in Preparation of

Triode Junctions During Drawing of Germanium

Monocrystals from Melt

PERIODICAL: Kristallografiya, 1960, Vol. 5, No. 6, pp. 957 - 958

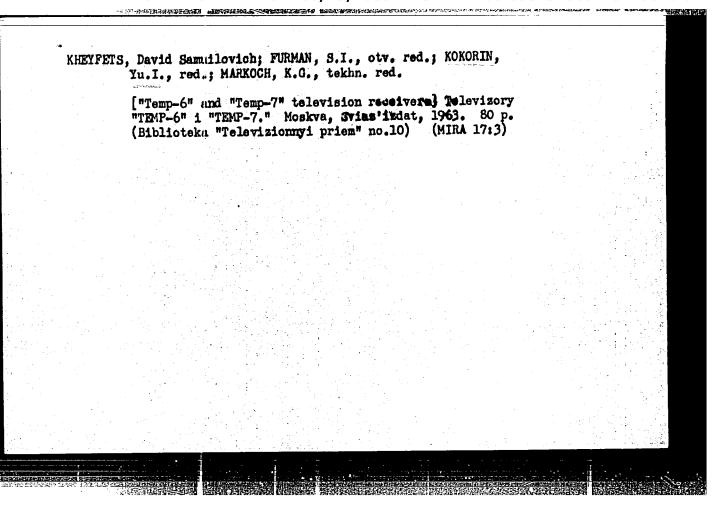
TEXT: The method of preparing semiconductor n-p-n structures, using the Peltier effect, is analogous to the method of change of the withdrawal rate from melt. In the Peltier method the rate of growth of a germanium monocrystal is altered by passing DC pulses through the crystal. The current which causes electrons to flow across the crystallization front from the melt to the crystal is known as the "faward current": it raises the rate of growth of the crystal. The current of the opposite polarity ("reverse current") reduces the rate of growth. The possibility of using the Peltier effect in this way Cardl/3

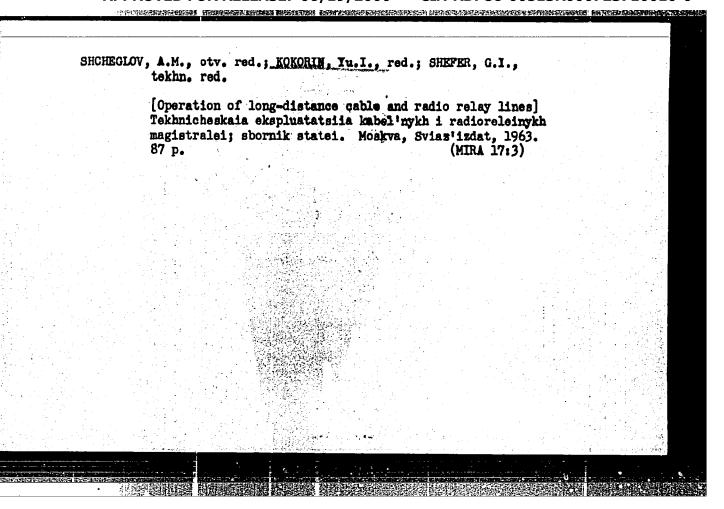
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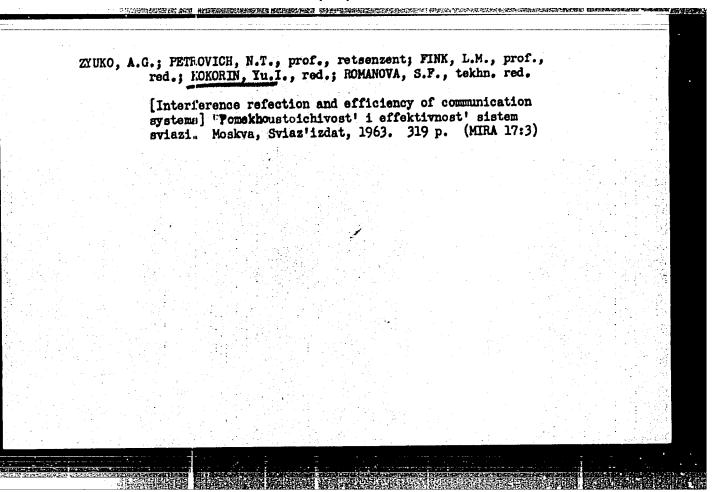
S/070/60/005/006/009/009 E201/E391

Use of the Peltier Effect in Preparation of Triode Junctions During Drawing of Germanium Monocrystals from Melt

was pointed out first by A.F. Ioffe in 1956 (Ref. 5). Pfann, Benson and Wernick (Ref. 6) described some practical applications of this idea. The present paper describes a study of the conditions necessary to produce n-p-n triodes. Germanium was melted in a graphite crucible, using high-frequency currents in an atmosphere of hydrogen. The rate of withdrawal was 3-4 mm/min and the rate of rotation of the crystal during growth was 60 r.p.m. Pure antimony and gallium were used as the alloying impurities. An n-type crystal of 10-15 mm length was drawn at the rate of 4 mm/min. Triode structures with p-regions of 15 - 70 μ thickness were obtained on passing a single reverse pulse of 80 A/cm<sup>2</sup> current density and 3-5 sec Card 2/3



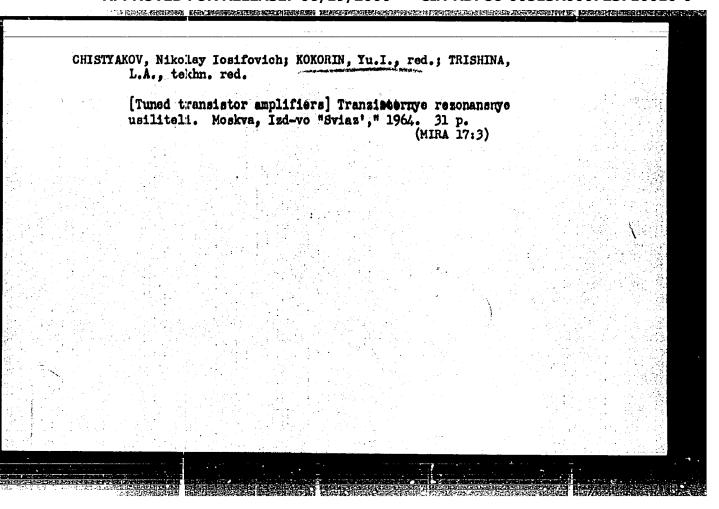




CORON, Isaak Yevseyevich; KOKORIN, Yu.I., red.

[Construction of skeleton diagrams and level diagrams of radio broadcasting channels] Postroenie skeletnykh skhem i diagramm urcvnei radioveshchatelinykh traktov.

Moskva, Izd-vo "Sviazi," 1964. 23 p. (MIRA 17:7)



KALABIN, Vladirir Sergeyevi'h; BORISOV, G.B., otv. red.; KOKORIN,
Yu.I., red.

[Analysis of circuits for the reinsertion of he d.c.
component in television] Analiz skhem vosstanovleniis postvinion sostvilaiushchei v televidenii. Moskva, Izd-vo
"Svinz'," 1964. 64 p. (MIRA 17:6)

COL'DENBERG, Lev Moiseyevich; KOKORIN, Yu.I., red.

[Principles of pulse techniques] Osnovy impul'snoi tekhniki. Izd.2., dop. Moskva, Izd-vo "Sviaz'," 1964. 431 p.

(MIRA 17:8)

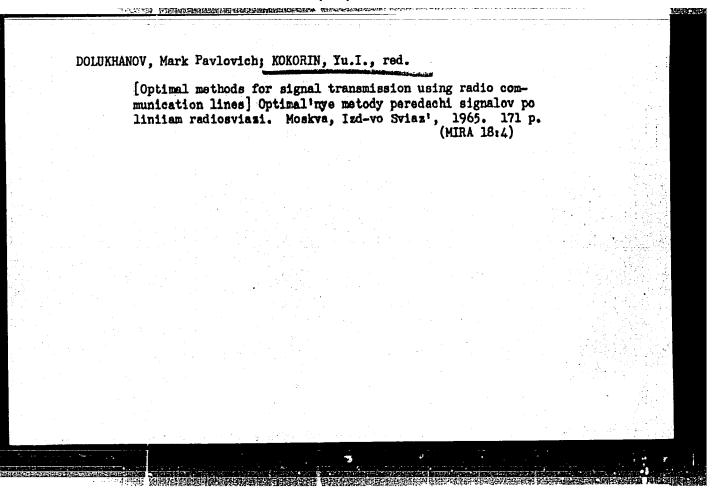
KHAYKOV, Aron Zalmanovich; KUKK, K.I., otv. red.; KOKORIN, Yu.I., red.

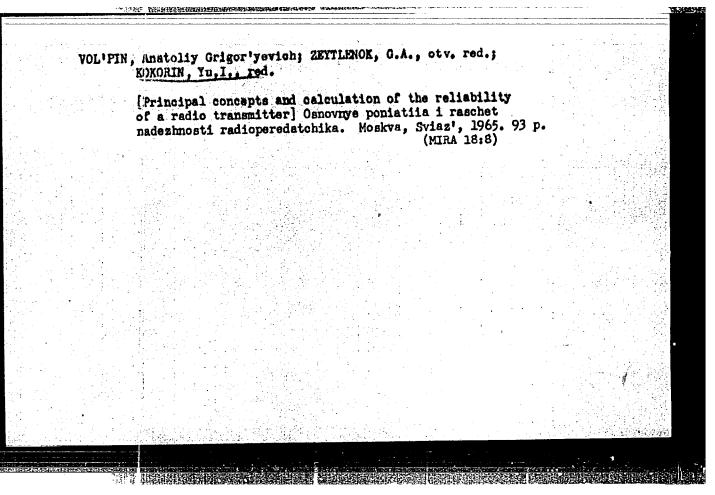
[Power amplifiers using multicavity klystrons] Moshchnye usiliteli na mnogoresonatornykh klistronakh. Koakva, Zzdvo "Sviaz", 1964. 167 p. (MIRA 17<sup>1</sup>11)

KHEYFETS, David Samuilovich; KOKORIN, Yu.I., red.

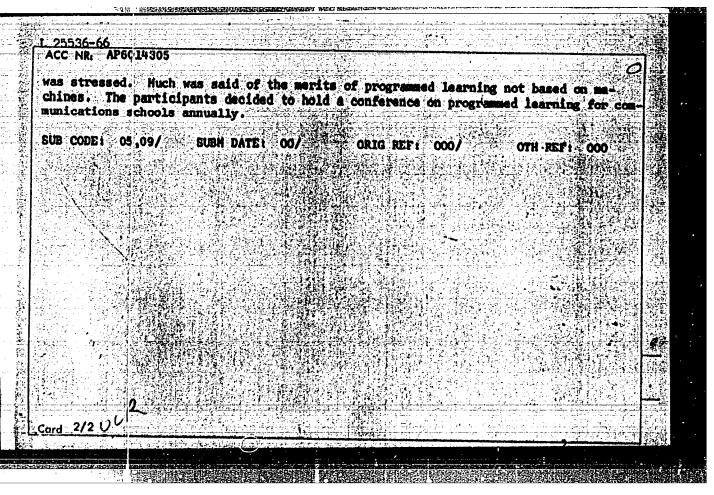
[The "TEMP" television receivers (models 6,7 and 6M)]
Televizory "TEMP" (Modeli 6, 7 i 6M). Izd.2., dop. Moskva, Sviaz' 1965. 64 p. (Biblioteka "Televiziormyi priem," no.19)

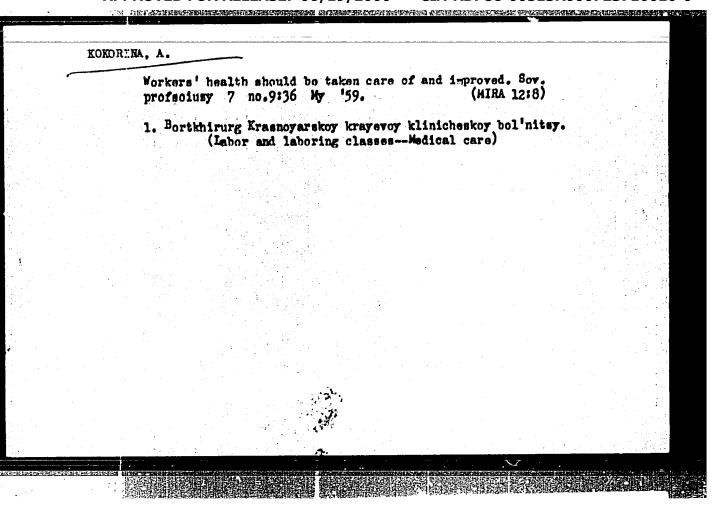
(HINA 18:4)





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AUTHOR:	Kokerin, Yu. I.				34	4.1
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USSR/Form Animals - General Problems.

Q-1

Abs Jour

: Ref Zhur - Biol., No 18, 1950, 83321

Author

: Kokorina, E.P.

Inst

Institute of Physiology, AS USSR.

Title

: Analysing Effects of Thyroid Hormones upon Physico-Chemical Properties of Lactic Fats. 1st Report. Effects of Emperimental Hyper- and Hypothyroidism upon Synthesis Processes

in Lactic Fats.

Orig Pub

: Tr. In-ta fiziol. AN SSSR, 1955, 4, 109-122

Abstract

Two series of tests were performed on 7 cows taken from herds of the Scientific Research Station, Institute of Physiology im. I.P. Pavlov AS USSR. In the first series of tests, the cows were fed sunflower oil, which had a deteriorating effect upon the quality of lactic fat (LF). Iodized casein (I) feedings followed. In the second test

Card 1/3

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USSR/Form Animals - General Problems:

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Abs Jour : Rof Zhur - Biol., No 18, 1958, 83321

sories, I feedings were given first and then LF. It was found that I softens and removes physicochemical property changes of LF, which sumflower oil has produced. Also, optimal doses of I were established, which affect processes of LF synthesis and LF quality the most. Increases of milk yields, achieved initially by large doses of I, may be sustained later by significantly lover dosages of the same preparation. The mik's fat content increases considerably thereby. In another test, effects of hypothyroidism upon LF synthesis were studied on 6 goats. From 2 of these goats the thyroid gland (TG) was removed 116 days before the test. In order to establish reaction differences caused by oil feedings in normal goats and goats without TG, all six goats were fed 1.25 gr of vegetable oil per 1 kg of live weight daily. Such feedings resulted in an increase of the loding count by 4.9 units in normal goats, and by 7.6 units in thyroidectomized goats.

Cord 2/3

### KOKIRINA, B.P.

Analysis of the effect of the thyroid hermone on physical and chemical properties of butterfat. Report no.2: Effect of air temperature and physical strain on the physical and chemical properties of butterfat. Trudy Inst.fiziol. 4:123-131 155. (MIRA 9:4)

1.Laberateriya fisielegii sel'skekhesyastvennykh shivetnykh. Zaveduyushchiy I.A.Baryshnikev. (Milk--Analysis and examination)(Thyroid gland)(Temperature--Physielegical effect)

### ICHORINA, E.P. Use of certain tests in studying the fundamental characteristics of higher nervous activity in cattle. Trudy Inst.fisiol. 4:147-165 '55. 1. Laboratoriya fisiologii sel'skokhosyays tvennykh shivotnykh.Zaveduyshchiy I.A.Baryshnikev. (Iervous system) (Cenditioned response) (Cattle)

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CCUUTRY

USSR

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Farm Animals.

2

Cattle.

AES . JOUR.

: RZhBiol., Ro. 3,

AUTHOR

Kokoring Fare

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as ussr.

TITLE

The Reflex Characteristics of Milk Secretion in Cows with Varying Mobility and Equilibrium

1959, No. 11990

in Cortical Nervous Processes.

ORIG. PUB.

Dokl. AN SSSR, 1956, 108, No 4, 746-749

ABSTRACT

: The reflexes of milk and fat flow were studied in cows with different typological characteristics of higher nervous activity at evening milking time. Two-hundred-and-eighty-six experiments were carried out on 9 highly productive cows of the brown Latvian and Dutch breeds with 2-8 lactations. As a result of the daily repetition of a specific complex of stimuli which were connected with the process of milking, stable conditioned reflexes of

CARD:

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Inst Physiology in 1. P. Pavlor
AS USSR

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ABS. JOUR. RZhBiol., No. 1959, No.

AUTHOR INST.

TITLE

ORIG. PUB.

ABSTRACT

: milk and fat flow were established in the cows. Any violation of the usual stereotype of stimuli (change of place, timo, milking sequence, replacement of the milking girl, etc.) created an inhibition of reflexes. In order to obtain maximal production it is imperative to preserve stability of conditions during milking. The different reaction of the cows to changed milking conditions is not determined by breed, age, time of lactation, magnitude of milk yield and the milk's fat content. The inhibi-

Card:

2/3

- USSR / Human and Animal Physiology. Nervous System.

T-10

Abs Jour

: Ref Zhur - Biologiya, No 1, 1959, No. 3884

Author

: Kokorina, E. P.

Inst

Title

! Notegiveney the estroyactive : Effect of Caffeine on Conditioned Reflex Activity in

Orig Pub

: Z. vyssh. nervn. deyat-sti, 1957, 7, No 5, 727-732

Abstract

: In 12 cows, the strength of the stimulation process was established on the basis of reaction changes in the stereotype (of motor reflexes on a food reinforcement), made up of 2 positive, and of 2 differentiation reactions. Changes in the higher nervous activity (a beyond-thelimits inhibition) were noted by administration to the cows of 0.36 - 1.44 gm of pure caffeine. No correlation was found between the rapidity of appearance and consolidation of the first conditioned reaction and the

Lat. Physiol . Agricultural animals Inst. Physiology in 1. P. Parlov AS USSR

USSR / Farm Animals. Cattle.

Q

Abs Jour : Ref Zhur - Biologiya, No 2, 1959, No. 7376

Author

: Kokorina, E. P.

Inst

: Not given

Title

: Higher Nervous Activity and Milk Productivity

of Cattle

Orig ?ub : Zh. obshch. biol., 1958, 19, No 2, 148-162

Abstract

: It was established on 21 cows of various breeds that the level of milk productivity and the quantity of milk fat during lactation is higher in cows of a strong, well balanced, active type (I) and, with some exceptions, in cows of a strong unbalanced type (II) in terms of their higher nervous activity than in cows of a sluggish and weak type (III). Lactation curves of the (I) group

Card 1/3

Inal Physiology im 1 P. Pavlor

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Atis Jour : Ref Zhur - Biologiya, No 2, 1959, No. 7376

reach a high level after parturition and become gradually lower; in cows of (II) group they proceed more steeply; lactation often teminates suddenly. In cows of the strong, well balanced, inert type the lactation curves decline slowly and gradually or staircase-like, in the cows of the (III) group the lactation curves are steadily maintained at a low level throughout the entire lactation period or decline sharply after having reached a high level after parturition. Daily milk yield fluctuations, the quantities of milk fat and the rapidity of milk discharge, changes within individual lactations are less intensive in cows with a high and medium high activity of cortical nerve processes than in cows with a

Cerd 2/3

(a/d 3/3

### KOKORINA, E.P.

Conditioned reflex of lactation and its inhibition in cows with various typological characteristics of higher nervous activity. Nauch. scob. Inst. fiziol. AN SSSR no.1:191-193 '59. (MIRA 14:10)

1. Laboratoriya fiziologii sel'skokhozyaystvennykh zhivotnykh (zav. - I.A.Baryshnikov) Instituta fiziologii imeni Pavlova AN SSSR.

(CONDITIONED RESPONSE) (LACTATION)

### KIMORINA, B.P.

Characteristics of the lactation reflex in cows with cortical nervous processes of different strength. Trudy Inst.fisiol. 8: 46-50 159. (MIRA 13:5)

1. Laboratoriya fiziologii sel<sup>\*</sup>skokhosyaystvennykh shivotnykh (zaveduyushchiy - I.A. Baryshnikov) Instituta fiziologii im. I.P. Pavlova AN SSSR.

(LACTATION) (TEMPERAMENT)

### IOKORINA, E.P. Method of catheterising the udder. Fisiol.shur. 45 no.12:1499-1505 (MIRA 13:4) 1. From the Laboratory for Physiology of Farm Animals, I.P. Pavlov Institute of Physiology, Leningrad. (UDDER) (GATHETERIZATION experimental)

# KOKORINA, E.P. Goordination of the secretory activity of individual quarters of the udder in cows. Fisiol. shur. 47 no.1:56-63 Ja '61. (MIRA 14:3) 1. From the Laboratory of the Farm Animal Physiology, Pavlov Institute of Physiology, Academy of Sciences of U.S.S.R., Leningrad. (IACTATION) (IACTATION)

# KOKORINA, E.P.

Coordination of the lactating activity of individual quarters of the udder in cows. Fiziol.zhur. 47 no.8:1024-1032 Ag '61.
(MIRA 14:8)

1. From the Laboratory of Physiology of Farm Animals, I.P.Pavlov Institute of Physiology, Leningrad.
(UDDER)

# ROKORINA, B.P. Higher nervous activity and milk productivity in cattle. Osv. AN SSSR, Ser.biol. no.6:905-914 N-D \*61. (MURA 14:11) 1. Institute of Physiology, Academy of the U.S.S.R., Leningrad. (NERVOUS SYSTEM)

### KOKORINA, E.P.

Methodology of evaluating the properties of basic nervous processes in determining the type of higher nervous activity in animals by conditioned motor food reflexes. Zhur. vys. nerv. deiat. 13 no.24361-370 Mr-Ap163. (MIRA 1619)

1. Laboratory of Farming Animals Physiology, Pavlov Institute of Physiology, U.S.S.R. Academy of Sciences, Leningred.
(NERVOUS SYSTEM) (CONDITIONED RESPONSE)

### KOKORINA, E.P.

Possibility of applying some indices in the determination of the nature of the force of an excitation and the mobility of nervous processes in establishing the nervous sytem type. Zhur.vys.nerv. deiat 14 no.1:95-101 Ja-F 164. (MIRA 17:6)

1. Laboratory of Physiology and Biochemistry of Lactation, Pavlov Institute of Physiology, U.S.S.R. Academy of Sciences, Leningrad.

KOKORINA, E.P.

Evaluation of typological characteristics of nervous processes when comparing the results of several functional tests. Zhu. vys. nerv. deiat. 14 no.3:532-536 My-Js \*54. (MIRA 17:11)

1. Laboratory of Physiology and Biochemistry, Pavlov Institute of Physiology, U.S.S.R. Academy of Sciences, Leningrad.

### KOKORINA, E.P.

Effect of various nutritional levels on nervous processes in animals in ontogenesis. Vop. pit. 22 no.6:66-67 N-D '63.

(MIRA 17:7)

1. Iz laboratorii fiziologii i biokhimii laktatsii (zav. - prof. I.A. Baryshnikov) Instituta fiziologii imeni I.P. Pavlova AN SSSR, Leningrad.

AUTHOR:

Abramson, Yu.M., Kokorina, L.F., Engineer

Engineer

TITLE:

Methods of Suppressing Radio Interference on Suburban Electrified Railways (Metody podavleniya radiopomekh na prigorodnykh elektrifitsirovannykh uchastkakh

zheleznykh dorog)

FERIODICAL: Vestnik Elektropromyshlennaya, 1959 Nr 3, pp 31-34 (USSR)

ABSTRACT:

On suburban lines where sub-station mercury-arc rectifiers are not grid-controlled most of the radio interference from electric railways originates in the rolling stock. The interference is propagated and radiated by the overhead conductor wires. Interference in the medium wave-length range can travel considerable distances but short and ultra-short wave-length interference is damped out quite quickly. The characteristics of interference originating in the main motors control equipment and pantographs of motor-coach stock are briefly described. The worst interference from motor-coaches is observed when they are running at high

Card 1/5

speed or are coasting at full speed. The suppression system for motor coaches differs from the systems that

Methods of Suppressing Radio Interference on Suburban Electrified Railways

have been developed for various types of electric locomotives in that no attempt is made to suppress the interference from each individual component, rather the whole equipment is considered as a single equivalent source of interference. Because of this suppression systems can be made simpler and more reliable. The equivalent circuit of a motor coach section, considered as a source of radio interference, together with suppression circuits is given in Fig.1. Interference can be much reduced by proper design of pantographs, using carbon or carbon-metal inserts in the pantograph and increasing the elasticity of the suspension. At the present time the radio interference from motor coach sections is suppressed by connecting an inductance between the pantograph and the electrical equipment to increase the high frequency impedance, whilst the source of interference is shunted by a capacitor of sufficiently low high-frequency impedance over the required frequency range. A schematic circuit diagram of the arrangement used is given in Fig. 2. The suppression circuit is

Card 2/5

Methods of Suppressing Radio Interference on Suburban Electrified Railways

tuned to a frequency of about 0.3 mc/s. The inductance required is about 500 microHenries. The construction of the inductance is described. Radio interference from traction substations is then considered, it originates mostly in the mercury-arc rectifiers and is at a frequency of 300 c/s and harmonics of this frequency. Very high interference levels are observed at frequencies of 0.16 - 0.55 Mc/s and little interference from traction substations is observed at 1.5 Mc/s. The level of interference from mercury-arc rectifiers, though somewhat dependent on the load, depends mainly on the control angles at which the rectifier is working. The level is much higher when grid control is used. In suburban sub-stations where grid control is not used it suffices to use capacitative suppression on the internal earthing circuits of the sub-station using condensers type KBG-P-6-1. The method of connecting the capacitors is explained. The importance of correctly locating and connecting some of the suppression equipment is discussed.

Card 3/5

Methods of Suppressing Radio Interference on Suburban Electrified Failways

In November - December, 1957 measurements were made of the effectiveness of interference suppression on a suburban electrified railway section. Both traction sub-stations supplying the section were provided with capacitors for interference suppression and two motor coach sections were provided with suppression equipment. Interference levels were measured with instruments types IP-12M and IP-14. Interference field levels over a range of frequency at a distance of 10 metres from the track when no suppression equipment is used are given in Fig.4 and the corresponding curves when suppression equipment is used, in both traction sub-stations and rolling stock, are given in Fig.5. In each case the upper and lower curves correspond respectively to the highest and lowest levels of interference measured during the tests. It will be seen that suppression is sufficiently effective to bring the interference below the required level over the frequency range of 0.16 - 1.5 Mc/s which is the important range. At frequencies above 20 Mc/s the interference is still

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Methods of Suppressing Radio Interference on Suburban Electrified Railways

above the permitted standard but this can only be overcome by improving the conditions of current collection. There are 4 figures.

Card 5/5

AYZBERG, R.Ye.; KOKORINA, L.K.; KOTS, V.G.

Buried extension of the meganticline in the southwestern Gissar Range. Sov. geol. 7 no.11:114-117 N '64. (MIRA 18:2)

1. Yugo-vostochnaya Karakumskaya geologicheskaya ekspeditsiya.

SHENDE, Sh.T.; KOKORINA, L.M.

Effectiveness of Azotobacter administered jointly with mineral fertilizers to rice. Mikrobiologiia 33 no.3:467-471 My-Je 164.

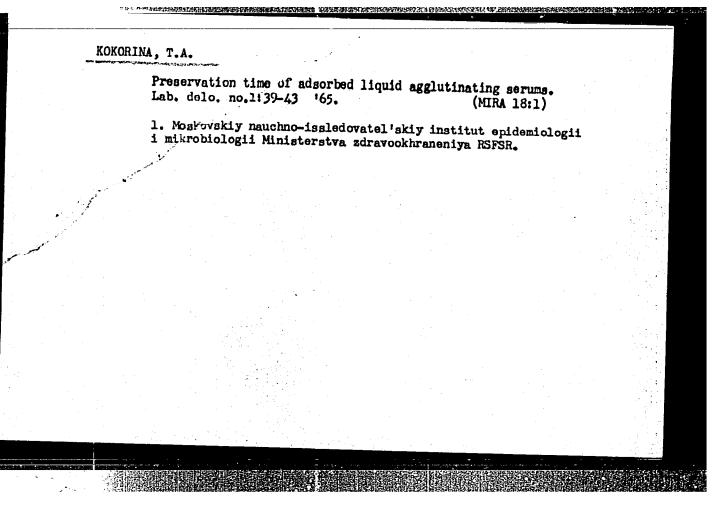
(MIRA 18:12)

1. Universitet druzhby narodov imeni Patrisa Lumumby i Kuban-skaya risovaya opytnaya stantsiya. Submitted December 6, 1963.

KUMENDANTOVA, A.L.; EHRUSHCHEVA, Ye.A.; BOTSMANOV, K.V.; KOKORINA, O.P.;
YUCHENKOVA, O.A.

Features of the course of combined disorders caused by the action
of ionising radiations and burn injuries. Med.rad. 4 no.10:54-59
0 159.

(RADIATION TEXUET exper.)
(BURES exper.)



KOKORINA, V. F.

Kokorina, V. F.

"The hygroscopicity of optical glass and its connection with chemical composition." State Order of Lenin Optical first imeni S. I. Vavilov. Moscow, 1956 (Dissertation for the degree of Candidate in Chemical Science)

Knizhnava letomis' No. 25, 1956. Moscow

FIRED 1 PAN: PRINIBIDITY 507,5035

Vessymmoys sostopaniys; trudy Tretlyse vessymmiyu. M. Lenngrad, 1959.

Stekhooheanoys sostopaniys; trudy Tretlyse vessymmogo sovetchaniya Lenderad, 1870 novebryan 1959 (Witreous State; Frankerinous of the Faird All-Unico Conference on the Vitreous State, Seal in Leningrad on Konstration, 1959) in serve, 184-70 MR 553R, 1950.

(Series: 184: Frank all pinserted. 3,200 copies printed.

Sponsoring Agencies: Institut khinis silikatov Akademii nauk SSSR. Vessoyumagve khimicheskope obahchsstvo iseni D.I. Mendalayeve and Gosudarstvemnyy ordena Zenina opticheskly institut iseni S.I. Vevilova.

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V.R. Bochever.

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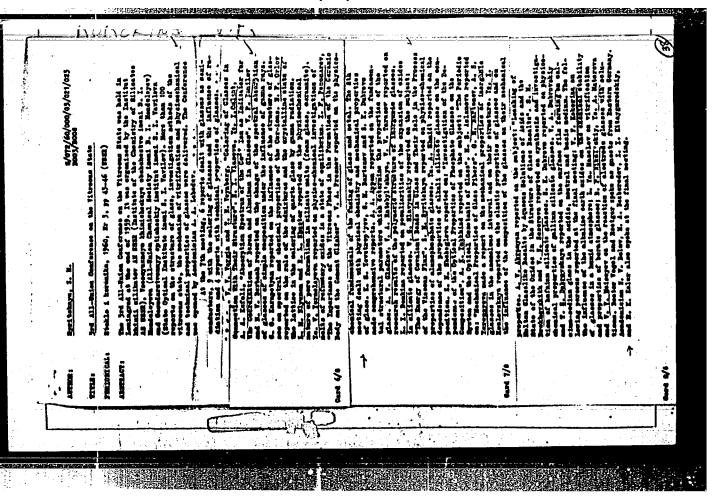
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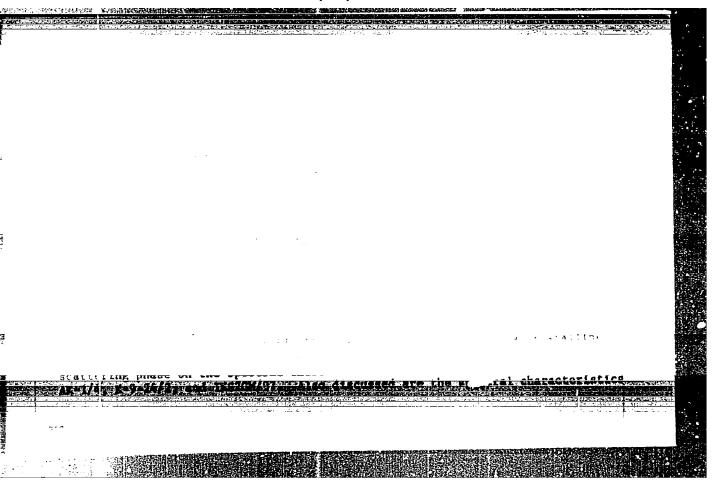
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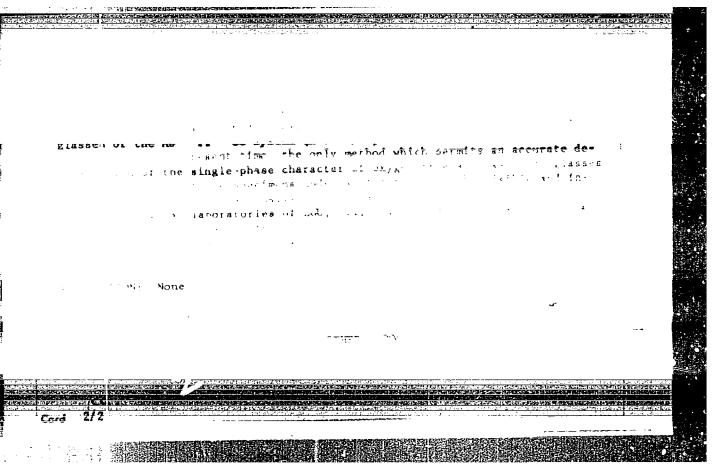
Same physico-chemical properties of semiconducting glasses containing tin and lead. A. M. Efimov, V. F. Kokorina.

[Hear semiconducting glasses based on yellow arsenic and selenium.

L. G. Ayo, V. F. Kokorina. (Not presented).]

Report presented at the 3rd National Conference on Semiconductor Compounds, Kishinav, 16-21 Sept 1963

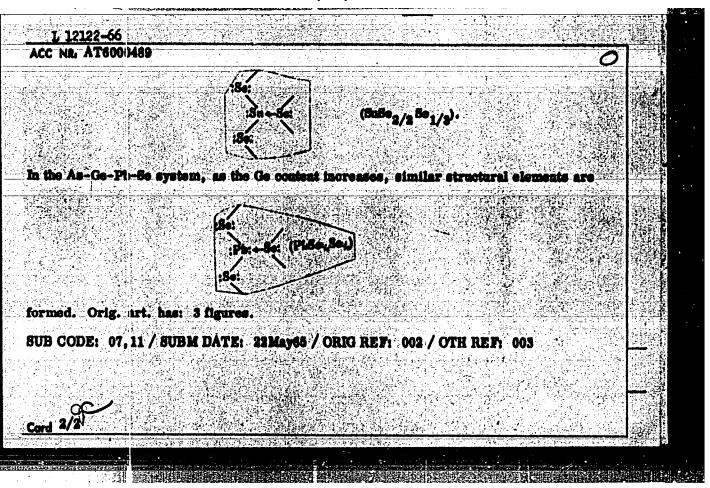


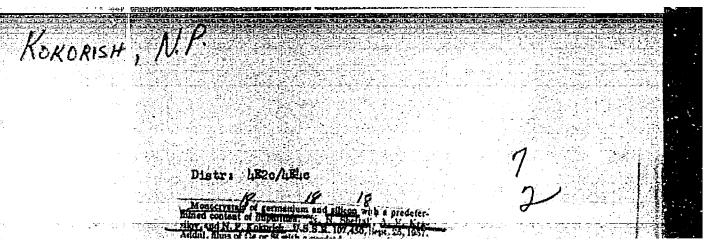


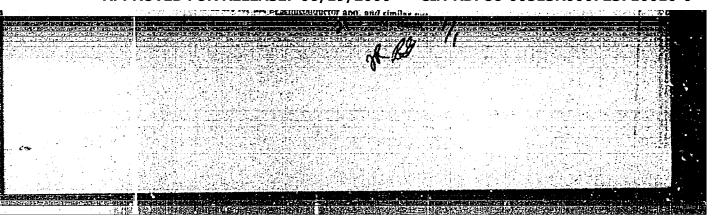
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RG: None		39 B+1	
ITLE: Some problems of glass	s structure according to stud		<b>خ</b> ـ
OURCE: <u>Vsesoyuznoye sovesh</u> 864. Stekloobraznoye sostoyan auka, 1965, 174-177	chaniye po stekloobraznomu liye (Vitreous state); trudy so	sostoyaniya. 4th, Leningrad, oveshchaniya. Leningrad, izd-v	ro i
OPIC TACS: glass, glass propound	perty, arsenic compound, ge	rmanium compound, selenium	
BSTRACT: Regions and glass plation between properties and e third, fourth, and fifth subgrarticular attention was given to	Composition for a series of a roups (in various combination	systems containing elements of	
s-Ge-Se * 5% In, Ga. The then naracteristics, crystallizability id electric properties were stu e glasses are determined by the e glass; this is illustrated by	rmal properties, density, mi y, chemical stability, viscos died. Other things being equ to change in the number of co differences in the systems Ge	icrohardness, spectral ity, refractive index, dispersion ial, changes in the properties of walent bonds per unit volume of the (where Ge has four bonds)	
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AUTHOR: Yelim	ov, A.M.; Kokorina, V.		4//	
ORG: None			$R_{I}$	
TITLE: Some pr Group IV of the p	operties and <u>structure</u> of eriodic system	oxygen-free glas	ses containing heavy elements of	
SOURCE: Vselo	yusnoye soveshchaniye po	stekloobraznom	sostoyaniyu. 4th, Leningrad,	
1964. Stekloolira Nauka, 1965, 177	iznoye sostoyaniye (Vitre 7–181	ous state); trudy	soveshchaniya. Leningrad, Izd-v	0 -
TOPIC TAGS: gl	ass, arsenic compound,	germanium comp	ound, selenium compound, tin	
ABSTRACT: The	effect of tin and lead on tudied in oxygen-free As-	glass formation	ind on some physicochemical here Ge was gradually replaced by	
the heavier analo	gs. In all the systems.	As-Ge-Sn-Se, As-	-Ge-Pb-Se, and As-Ge-Sn-Pb-Se ential changes in the position of th	1.72
boundaries of gla	ss formation as compare	d with the origina	1 As-Ge-Se system, and defects	
			h excess Se forms SaSe <sub>4/2</sub>	
In the As-Ge-Sit-	Se system, as the selenic	im present becom	as those formed by germanium. sea insufficient for the formation of	<b>26</b>
	ra, the following new stru	ictiral elements	appoar:	
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KOKORISH, N. P., SHAMBO, N. A., and SHEFTAL, N.N.

Institute of Crystallography, Adad. Sc., Moscow, "Some Peculiarities in Crystallaguation of Silicium and Germanium Films and Silicium Single Crystals" (Section 14-8) a paper submitted at the General Assembly and International Congress of Crystallography, 10-19 Jul 57, Montreal, Canada.

c-3,800,189

Ko Ko Rish, n.P.

AUTHOR:

SHEFTAL', N.N., KOKORISH, N.P., KRASILOV, A.V. PA - 2359
The Crystallization of Monocrystalline Layers of Silicon and
Germanium from the Gaseous phase. (Kristallizatsiya monokristallicheskikh sloyevkremniya i germaniya iz gazovoy fazy, Russian).

PERIODICAL:

Izvestila Akad. Nauk SSSR, Ser. Fiz., 1957, Vol 21, Nr 1,

pp 146 - 152 (U.S.S.R.) Received: 4 / 1957

Reviewed: 5 / 1957

ABSTRACT:

The present work investigates only the crystallization of silicon on silicon and germanium on germanium. According to a general survey of the problem the barrying out of the experiments is described. These experiments concerning pickling and breeding of non-orientated and orientated silicon- and germanium crystals disclose the real structure and the growth mechanism of these crystals.

Some conclusions: Crystallization from the gas phase is important for the production of monocrystalline layers with assumed constants or variable composition. Especially plane p-n transitions can be obtained in this manner. Crystallization of silicon and germanium at atmospheric pressure is obtained in the best and most simple manner by the decomposition of SiCl<sub>4</sub> and GeCl<sub>4</sub> in hydrogen at

Card 1/2

high temperatures. A monocrystalline growth of fragments of a micron of up to 200 \mu and a breeding surface of up to 2,5 cm<sup>2</sup>

PA - 2359

The Crystallization of Monocrystalline Layers of Silicon and Germanium from the Gaseous Phase.

was obtained for germanium. The practical suitability of the method was confirmed by the successful production of plates. These plates are suited for the production of triodes of the type p-n-i-p. On the occasion of crystallization from the gaseous phase at atmospheric pressure, growth not only takes place by means of single atoms or atom groups, but also by means of very small crystals. In spite of this fact the lattices thus produced possess a degree of perfection which is sufficient for technical purposes. (9 illustrations).

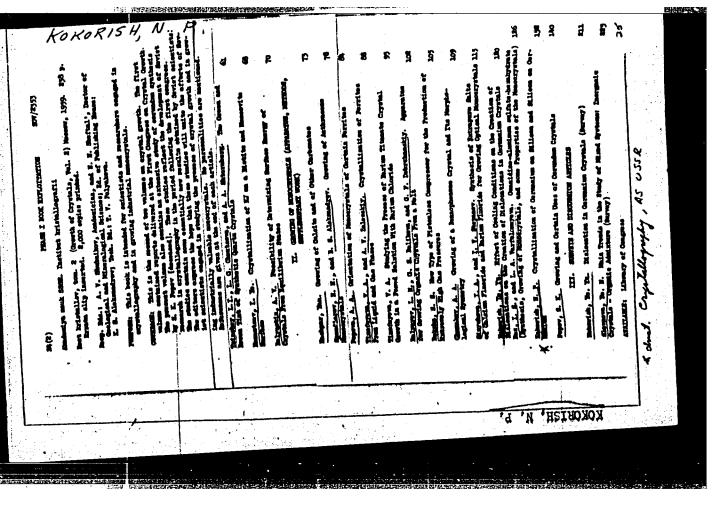
ASSOCIATION: Institute for Chrystallography of the Academy of Science of the U.S.S.R.

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AUTHOR:

Kokorish, N. P.

TITLE:

Crystallization of germanium on silicon and of silicon on germanium

PERIODICAL: Referativnyy zhurnal, Metallurgiya, no. 4, 1962, 50, abstract 40326 (V sb. "Rost kristallov. T. 2". Moscow, AN SSSR, 1959, 132 - 139)

The process of growing Ge on Si and Si on Ge was studied. When growing Ge on 3i, monocrystalline Si plates with an area of  $0.3 - 1 \text{ cm}^2$  and 0.4 - 1 mm thick were used as a backing. Before applying Ge the plates were ground and polished and then pickled during 2 - 4 min in a boiling 30% NaOH solution. The application of Ge was made from  $\text{GeCl}_{1}$  vapor by the hydrogen method at  $750 - 940^{\circ}\text{C}$ . It has been shown that at a temperature of  $\leq 800^{\circ}\text{C}$  the silicon backing is not covered with Ge, and the precipitation process begins at  $850^{\circ}\text{C}$  whereby an unbroken coverage of the Si plate is not achieved. Ge precipitates in the form of black spots mainly at the boundaries of the steps, and no unbroken and firm precipitates have been produced. The application of Si on Ge was made by decomposing SiCl<sub>1</sub> with hydrogen at  $900 - 920^{\circ}\text{C}$ . Before applying Si film the Ge plates were ground, polished with chromium oxide and pickled in  $\text{H}_2\text{O}_2$  during 10 min. Unbroken films

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l micron thick were produced, representing grown together parallel Si crystals.  B. Turovskiy  [Abstracter's note: Complete translation]	Crystallization of			S/137/62/000/0 A052/A101	103/054/201
[Abstracter's note: Complete translation]	1 micron thick were pr	roduced, represer	ting grown tog	ether parallel Si cr	ystals.
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24.7000

AUTHORS:

Kokorish, N. P., and Sheftal', N. N.

TITLE:

Morphology of polycrystalline silicon films

SOURCE:

Akademiya nauk SSSR. Institut kristallografii. Rost

kristallov, v. 3, 1961, 351-356

TEXT: This and the two following papers describe the author's work carried out in 1954 on preparing germanium and silicon films from gas phase. The present paper deals with the morphology of polycrystalline silicon films prepared from gas phase by reducing SiCl<sub>4</sub> with H<sub>2</sub>; the purpose of the study was to find why electrical properties of these films are variable. A stream of hydrogen, containing SiCl<sub>4</sub> vapor, was passed at the rate of 5 cm/sec. through a quartz tube placed in an electrical resistance furnace. Silicon was deposited in a portion of the quartz tube and on objects placed in it. To study the mechanism of deposition of silicon a graphite block of 10 x 15 x 150 mm dimensions was placed

Card 1/3

30539 S/564/61/003/000/010/029 D207/D304

Morphology of ...

inside the quartz tube. The block was somewhat larger than the region where crystallization occurred (this region is known as the crystallization or reaction zone). To make the films more uniform, the temperature gradient in the quartz tube was small. The temperature distribution (T) in the crystallization zone, the variation of the film thickness (A) along the graphite block, and the mean magnitude of crystallites (6) of which the film was composed are all given. It was found that the film was very thin at the beginning of the crystallization zone, where it consisted of a very large number of small grains. Both the film thickness and the magnitude of single grains increased along the crystallization zone in the direction of gas flow. Towards the end of the crystallization zone, the mean size of grains still increased, but the film became discontinuous. Finally, at the end of the zone, single or small groups of large crystallites (up to 200 \mu. in size) were found instead of the film. Sections of the film at right angles to gas flow showed that at the beginning of the crystallization zone the film consisted of several layers of fine grains. In the middle of the crystallization zone, the number of these layers decreased. Towards the end of the zone, the film consisted

Card 2/3

30539 S/564/61/003/000/010/029 D207/D304

Morphology of ...

of a single layer. The results obtained are discussed in terms of nucleation and of crystal growth velocities. It is concluded that portions of the films formed in the middle of the crystallization zone are suitable for electrical applications because of their single-layer (effectively monocrystalline) structure. Elsewhere, the films are either amorphous or fine-grained with intergrain layers (at the beginning of the crystallization zone) or are discontinuous (at the end of the zone). Unidirectional laminar flow of gas tends to produce films whose properties vary along their length in the crystallization zone. There are 7 figures and 4 references: 2 Soviet-bloc and 2 non-Soviet-bloc. The references to the English-language publications read as follows: R. P. Ruth, I. C. Marinace and W. C. Dunlap, J. Appl. Phys., 31, 6, 995-1006, 1960; I. B. M. Journal, no. 3, 1960.

Card 3/3

S/564/61/003/000/011/029 D207/D304

24 7000

Kokorish, N. P.

AUTHOR:

Features of monocrystalline germanium film deposition

from gas phase

SOURCE:

Akademiya neuk SSSR. Institut kristallografii. Rost

kristallov, v. 3, 1961, 357-362

TEXT: The author describes a method of depositing germanium films on germanium plates. Deposition was carried out in a quartz tube heated to 600 - 920°C. Hydrogen, carrying GeCl<sub>4</sub> vapor, was passed through the

tube at the rate of 5 - 8 cm/sec. Above 700°C, the reaction GeCl<sub>4</sub> + 2H<sub>2</sub> = Ge + 4HCl produced free germanium which was deposited in a region of 5 - 7 cm length, known as the crystallization zone. Ger-

a region of 5 - 7 cm length, known as the crystallization zone. Using manium plates placed in the crystallization zone became covered by germanium films. The author studied the position and length of the crystallization zone at maximum temperatures ranging from 655 to 920°C. The

Card 1/3

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Features of ...

longest crystallization zone was obtained at 800 - 850°C, and it was found that the zone length decreased with increase of the temperature gradient steepness. A second crystallization zone sometimes appeared in regions where temperature fell rapidly. Occasionally a crystallization zone consisted of several noncontiguous regions. To determine the quality of films as a function of the crystallization zone temperature, germanium plates cut along the (111) plane were etched in CP-4, washed, dried and placed in the crystallization zone in a graphite or quartz holder. The effect of concentration of GeCl<sub>4</sub> vapor was also studied; this concen-

tration was altered by varying the temperature of a GeCl vaporizer

from -30 to +20°C. It was found that germanium films of maximum thickness were obtained on plates at a crystallization temperature of 800°C. To increase the length of the crystallization zone, the temperature distribution in it should be made uniform, and temperatures in the zone should be within the range 750 - 900°C. The thickness of germanium films increased with the duration of deposition and with the concentration of GeCl<sub>4</sub> vapor in hydrogen; the thickness was not greatly affected by the

Card 2/3

3) 540 8/564/61/003/000/011/029 D207/D304

Features of ...

rate of flow of hydrogen which was varied from 15 to 100 liter/hour. The author points out that appearance of a second crystallization zone indicates that a gradual decrease of the rate of deposition with increase of temperature above 800°C and complete absence of deposition at 900°C or higher temperatures is due to partial or complete transfer of freshly formed germanium vapor outside the limits of the first crystallization zone. The rate of this transfer increases with the increase of temperature and with a lowering of saturation because germanium particles are then reduced and small particles are difficult to deposit. There are 9 figures.

Card 3/3

S/564/61/003/000/012/029 D228/D304

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AUTHORS:

Sheftal', N. N., and Kokorish, N. P.

TITLE:

Reciprocal grafting of crystals of silicon and

germanium

SOURCE:

Akademiya mank SSSR. Institut kristallografii. Rost

kristallov, v. 3, 1961, 363-370

TEXT: This work is a continuation of previous research by N. P. Kokorish (Ref. 6: Sb. Rost kristallov, v. 2, Izd. AN SSSR, 1959, 132-139) on the epitaxial grafting of Si and Ge crystals. The theory of epitaxial grafting was developed by P. D. Dankov (Ref. 3: Trud. 2-y konferentsii po voprosam korrozii, 11, 121, 1943) and later perfected by G. M. Bliznakov (Ref. 4: Godishn. na Sof. univ. Fiz. khim. fak., kn. 2. Khimiya, ch. I, II, 65-71, 1956); P. S. Vadilo (Ref. 2: Uchen, zap. Kurskogo gos. inst., 4, 143, 1957) and L. E. Collins et al have studied other aspects of this problem—the grafting of alkali-halide crystals on mica and the growth of Ge crystals on halite. Experimental procedure.

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Card 1/3

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Reciprocal grafting of ...

Etched crystals of Ge and Si, cut along three planes, are respectively coated with films of crystalline Si and Ge by the method of N. N. Sheftal' et al (Ref. 8: Izv. AN SSSR, ser. fiz., 21, no. 1, 146-152, 1957)—the reduction of the corresponding chloride by hydrogen. (a) Grafting of Ge on Si: A 30µ-thick layer of Ge, largely consisting of unoriented semicrystalline aggregates, precipitates at 800°C; oriented crystals appear at 840° on (100), (110) and (111) surfaces, but the coating is patchy and peels off at higher temperatures. (b) Grafting of Si on Ge: A semicrystalline layer is deposited below 900°; close to the melting-point of Ge (937.2°) an oriented crystalline layer is formed with a thickness of up to 30µ; the coating is durable and has an n-type conductivity. The increase in the temperature—and the consequent decrease in the supersaturation—is believed to be responsible for the successive formation of hemi- and holo-crystalline growths. The absence of any Ge precipitate on Si above 900°, however, may be due to the decrease in the size of the Ge particles separating out in the gas stream; their deposition is thus impeded, and they are removed from the crystal-lization sphere in the gas stream. The grafting of Ge crystals probably

Card 2/3

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Reciprocal grafting of ...

requires a weaker degree of supersaturation than was achieved in these experiments. The greater ease with which Si accumulates on Ge results from the operation of bilateral tension—as compared with bilateral compression in the case of Ge grafting—on the accretivelayer by the parent crystal's orienting forces, and so the growth of Si shifts to the region of its higher supersaturation. In conclusion, the authors the region of its higher supersaturation. In conclusion, the authors stress the need to perfect the crystallization method so that a homostress the need to perfect the crystallization method so that a homostress the need to perfect the crystallization method so that a homostress and continuous coating of Ge may be obtained on Si. There are figures and 9 references: 6 Soviet—bloc and 3 non—Soviet—bloc. The references to the English—language publications read as follows: L. E. Collins et al, Proc. Phys. Soc., B, 65, 10, 394, 825 (1952); F. X. Hassion et al, J. Phys. Chem., 59, 1076, 1955.

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8/181/61/003/002/007/050 B102/B204

AUTHORS:

Kurov, G. A., Sheftal', N. N., and Kokorish, N. P.

TITLE:

Investigation of coarse-crystalline germanium layers obtained

by pyrolysis from the gaseous phase

PERIODICAL: Fizika tverdogo tela, v. 3, no. 2, 1961, 370-372

TEXT: Thin, fine-crystalline germanium layers are characterized by a very low resistivity, and have usually p-type conductivity. According to published data, germanium layers with crystals of \$\precept{25} - 10\mu\$ and more, should depend on the size of the crystals and on the impurities with respect to their properties. In order to check this, the authors investigated the electric properties of 10 - 50\mu\$ thick germanium layers, which had been vaporized on quartz backings, by means of the so-called hydrogen method. Hydrogen was conducted over liquid GeCl<sub>4</sub> and later into a quartz tube heated to 700-900°C; the reaction GeCl<sub>4</sub>+2H<sub>2</sub>=Ge+4HCl took place. The excess in hydrogen, the hydrogen chloride, and small quantities of Ge and GeCl<sub>4</sub> were drained off into the atmosphere, the main Card 1/4

S/181/61/003/002/007/050 B102/B204

Investigation of coarse-crystalline ...

Card 2/4

part of the germanium crystallized on quartz. Besides quartz, also polished graphite backings were used. All backings were previously subjected to vacuum heat treatment. In the case of crystallization times of from 20 minutes to 1 hr, layer thicknesses of 3-5 \mu and up to 50 \mu were produced. The GeCl used was spectrally pure. The structure of the crystallization zones was non-uniform - at the beginning of the zone the crystals were not larger than  $\simeq 0.1 \mu$ , in the middle part 5-10  $\mu$ , and at the end of the zone they were 40-50  $\mu$ , several crystals attained up to 200 µ. It was found that the resistivity of germanium increases exponentially with increasing size of the crystallites. The layers crystallized onto graphite showed a dependence of the kind of conductivity on the size of the crystallites. Crystallites of the size of O. 1 were of p-type conductivity; at 3-5 \mu the thermo-emf passed from positive to negative values, and the coarse-crystalline layer, beginning with 3-5 pc, had n-type conductivity (at room temperature). The layer structure on graphite was equal to that on quartz, with the exception that the germanium crystals on quartz, independent of the size of the crystallites, showed p-type conductivity. Layers of thickness 10-20 \mu had a resistivity of Q = 28-35 ohm-om, which is by three orders of magnitude higher

Investigation of coarse-crystalline ...

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than the o of the fine-crystalline layers. Heating of 2-3 hr at 500-600°C diminished the resistivity of these layers to 25 ohm.cm. Experiments were also made in order to alloy the germanium layers formed with impurities. For this purpose, spectrally pure phosphorus chloride (donor) and borobromide (acceptor) were used. The introduction of phosphorus was followed by the occurrence of n-type conductivity, which was in all cases independent of the size of the crystallites; boron was analogously followed by p-type conductivity. Both kinds of impurity decreased the resistivity of the coarse-crystalline layer to 5-6 ohm.cm. The effect produced by impurities upon the kind of conductivity was exactly the same as in the case of macroscopic monocrystals. The results of the investigations show agreement with the assumptions made in Ref. 6 concerning the pyrolysis of germanium layers. The difference in crystalline size in the crystallination zone is explained by the fact that in the mixture of HCl+H, and germanium vapor the crystallization centers accompany the flow, deport, whereby the number of remaining crystals is reduced, and, consequently, increased in size. That is why, at the beginning of the crystallization zone, small crystals occurred, which were

Card 3/4

Investigation of coarse-crystalline ...

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followed by larger and larger ones. G. I. Spiridonova took part in the measurements. There are 3 figures and 7 references: 4 Soviet-bloc and 3 non-Soviet-bloc.

ASSOCIATION: Institut kristallografii AN SSSR (Institute of Crystallography, AS USSR)

SUBMITTED: April 4, 1960

Card 4/4

s/058/62/000/008/134/ A160/A101

AUTHOR:

Kokorish, N. P.

TITLE:

The crystallization of germanium on silicon and silicon on

germanium

PERIODICAL:

Referativnyy zhurnal, Fizika, no. 8, 1962, 31, abstract 8-4-61y (In collection: "Rost kristallov. T. 2". Moscow, AN SSSR, 1959,

132 - 139)

The conditions under which a mutual growth of germanium and silicon would take place were experimentally investigated. Attempts to grow-on germanium on silicon at temperatures of  $\angle$  800°C failed. At temperatures higher than 850°C and up to the smelting point of germanium (958°C) an oriented but not continuous growth of germanium on silicon was obtained on plane (111). was possible to grow-on a continuous layer of germanium on silicon on plane '(110), which only unstably adhered to the sublayer. Attempts to grow-on silicon on germanium proved to be successful only within a short range of temperatures from 880°C to the sublayer smelting point. The obtained silicon layers were continuous. Ye. G.

[Abstracter's note: Complete translation]

Card 1/1

41653 s/058/62/000/010/063/093 A061/A101

24.7000

AUTHOR:

Kokorish, N. P.

TITLE:

Crystallization of germanium on silicon and of silicon on germanium

PERIODICAL:

Referativnyy zhurnal, Fizika, no. 10, 1962, 25, abstract 10E192 (In collection: "Rost kristallov. T. 2", Moscow, AN SSSR, 1959,

132 - 139)

TEXT: The conditions for the intergrowth of Si and Ge were investigated experimentally. The deposition of Ge on Si did not succeed at temperatures lower than 800°C. Above 850°C and up to the melting point of Ge an oriented, though not continuous, deposition of Ge on Si took place in the (111) plane, while on the (110) plane it was possible to build up on Si a Ge film being continuous though not adhering stably to the backing. The deposition of Si on Ge succeeded only in a narrow temperature range from 880°C to the melting point of the backing. The Si films of ained were of the continuous kind.

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Ye. Givargizov

[Abstracter's note: Complete translation]

Card 1/1

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SA(2) ENGRY I NOW RIPIDITATION SOV(235)	SEE. Bartines brist	Back hateralism, ton. 2 (Security of Caywalls, Val. 2) messes, Arrest and Erman ally inserted. 2,000 ceptes principal.	Bong, Mais I. A. V. Sheintliny, Amshrederine, and S. M. Sheithle, Deriver of Grainfilm) and Minimal-Laffed, Relationes   Mo. of Publishing Brenot E. A. Addressivery Souls, Mais T. V. Polyshows.	FRECE: This best is intended for exionities and personalers compact in extensionally and in growing industrial mesentrials.	CONTRACT. This is the posted of two values on crystal gravits. To first unions emission appears to failurers as the First Congress on Crystal Courts.	in present value also contains an extractive con- ing S. E. Mary (Second). Then relative prices the furthermost of British by S. E. Mary (Second). The second relative the first congress.	The state is appeared to the constitution of t	int estantiate sagged in contribe the present of styling Green and in pre-	Digeress on give of the set of each article.	Manual and the state of the sta	Bearder, L. D. Oppublication of II on a Rotte and Bearting	Divertia, A. V. Postitity of Debestiing Surban Story of	COUNTY, MANAGER, MANAGER, MATERIAL (APPRAISED, METEROS,	SEPTIMENT VOIC)	Badpar, Ma. Overlag of Calette and of Other Carbenttes 17	Constants, E. E., and B. C. Alabamatyre. Overing of Arthresses.	Depen, A. A. Orientation of Descriptule of Cartain Persies &	Dem Liquid and Oat Raines. Committeeton of Persities On News Son Liquid and Oat Raines.	Mandayors, V. A. Sunfring the Presses of Barius Steamte Crystal.	Bingry L. M., G. E. Billow, and G. P. Dherbandly. Appareta	Matthe, 6. S. Bry type of References Ompresser for the Production of Research Mat Asserted	General, A. A. Overlag of a beaugheome Cyreal and Its buybe-	Employee, L. L., and L. T. Buynner. Synthesis of Schroppes Shike of Thicken Theories and Region Plantice and Region Plantice Con Course Courses Courses (not no course).	Riflect of Conling Conditions on the Cr	and of the Creation of Malcontines in Germanian Crystale 120 of the A. Warthington. Consistent additional matrix of the Constitution of the Consti	Crystallimation of Cormanium on Alliess		ZII. SHAZI AND DEPENDENCE AMERICAN	Releastion in Cornecty	Staff of Mark Systems Incomets	Liberty of Ongo		
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## "APPROVED FOR RELEASE: 06/19/2000 CIA-RDP86-00513R000723710010-0

24.7100

78120

SOV/70-5-1-29/30

**AUTHORS:** 

Kokorish, Ye. Yu., Sheftal, N. N.

TITLE:

Growth of Dislocation-Free Single Crystals of.

Germanium. Brief Communications

PERIODICAL:

Kristallografiia, 5, No. 1, pp. 156-57, 1960.
Dislocation density in artificially grown crystals of germanium varies from 103 to 105 per cm<sup>2</sup>, If the crystals, growing while pulled from the melt, are heated additionally and cooled off at a very low rate, they can be obtained dislocation-free. Using the method suggested by W. C. Dasch, and seeds in which the dislocation density did not exceed 103 per cm<sup>2</sup>, the authors produced several crystals, up to 50 g each, and measured their dislocation density and other properties. The results are compiled in

Table A. Institute of Crystallography, Acad. Sci. USSR.

Growth of Dislocation-Free Single Crystals of Germanium. Brief Communications

78120 80V/70-5-1-29/30

Key to Table A; (a) Specimen number; (b) Dislocation density per cm<sup>2</sup>; (c) Resistivity, ohm cm; (d) Diffusion length, mm.

			Table 1							
į	(a)	(P)	, (c)	(d)						
	13-797	12 3	1,4 1,3	1,1						
	11-799 11-831	Ů	0,8 0,6	0,6						
	11-826 13-873	3-10* 5-10*	1,0 0,6	0,6 0,4						

E. V. Myakinenkova and V. K. Bichev are acknowledged for assistance. There are 2 figures; 1 table; and 6 references, 2 U.S., 1 U.K., 1 German, 1 Dutch, 1 Soviet. The U.S. and U.K. references are: W. C. Dasch, Electr. Eng., XII, 1156, 1958; A. D. Rosi, RCA Rev., 19, 349-386; E. Billing, Proc. Roy. Soc., 235, 37, 1956.

Card /3

\$/070/60/005/005/014/017<sup>81125</sup> E132/E360

TITLE:

Kokorish.

Influence of the Peltier Effect on the Perfection of Single Crystals of Germanium Obtained by the Method of Withdrawing a Crystal Seed from a Melt

Kristallografiya, 1960, Vol. 5, No. 5, PERIODICAL: pp. 815 - 816

When a single crystal is grown by withdrawing a seed crystal from a melt one of the important conditions influencing growth is the way in which the latent heat of solidification is removed from the liquid/solid interface. Inadequate removal of heat can lead to fluctuations in the rate of growth. This produces imperfections in the crystal. The application of the Peltier effect in semiconductors for this purpose was suggested by Ioffe (Zh. tekh.fiz., Vol. 26, 478, 1956). In the case of semiconductors with n-type conductivity the absorption of heat in the crystallisation front proceeds when the flow of electrons is from the melt to the crystal, i.e. when the crystal is made positive with respect to the meit. This is called the forward current and a reverse current will generate heat at the interface. Card 1/3

S/070/60/005/005/014/017 E132/E360

Influence of the Peltier Effect on the Perfection of Single Crystals of Germanium Obtained by the Method of Withdrawing a Crystal Seed from a Melt

The influence of a forward current on the crystallisation of germanium was studied experimentally. Crystals of Gerwere grown in an atmosphere of H<sub>2</sub> with the seed crystal set along the

[111] direction, a rate of withdrawal of 1 mm/min and a rate of rotation of the crystal of 60 rpm. A constant current was passed through the crystal from a rectifier. Plates were cut transversely from the rod-crystal resulting at different distances from the seed. They were etched in a boiling solution of 12 g KOH and 8 g K<sub>3</sub>Fe(CN)<sub>6</sub> in 100 g water and the density

of the dislocations was counted. Longitudinal and transverse plots of the dislocation density distribution were made. Both types of curves showed minima (at about 2.5 cm from the seed and at the axis of the 1.4 cm dia. crystal). It is concluded

Card 2/3

S/070/60/005/005/U14/017 E132/E360

Influence of the Peltier Effect on the Perfection of Single Crystals of Germanium Obtained by the Method of Withdrawing a Crystal Seed from a Melt

that the density of dislocations is more uniform for these crystals grown with a current than it would have been without a current and that the method is of practical use.

There are 2 figures and 6 references: 1 Soviet, 1 German and

There are 2 ligures and o references: I boviet, I de. 4 English.

SUBMITTED: January 26, 1960

Card 3/3

B/053/60/072/003/003/004 B019/B056

24.7700 (1043,1143,1559)

Kokorish, Ye. Yu. and Sheftal', N. N.

TITLE:

Dislocations in Semiconductor Crystals

PERIODICAL:

Uspekhi fizicheskikh nauk, 1960, Vol. 72, No. 3,

pp. 479 - 494

TEXT: The authors have studied the effect of dislocations upon the electrical properties of semiconductor crystals, the formation of dislocations in growing semiconductor crystals, and the action of dislocations upon semiconductor instruments. In the first part, the lattice distortion caused by dislocations and the change in the forbidden band width connected herewith is discussed. Furthermore, the space charge and the resulting decrease of carrier mobility, as well as the increase of its scattering and the increase of carrier recombination are discussed. The results obtained by non-Soviet scientists concerning the recombination properties of dislocations, which are formed in growing crystals, are discussed, after which the interaction of dislocations with impurity atoms is described. Thus, it is shown that the formation of an impurity

Card 1/3

Dislocations in Semiconductor Crystals

S/053/60/072/003/003/004 B019/B056

atmosphere by dislocations leads to a decrease of the effective carrier trapping cross section, and further, the impurity atoms render the shift of dislocations more difficult. Of the methods of visualizing dislocations, the metallographic method, the X-ray method, and the "decoration" method are discussed in detail. For the first-mentioned method, the composition of etching agents for germanium, silicon, Ge-Si alloys and InSb are given in a table, and the etching techniques are discussed. The X-ray method makes it possible to determine the dislocation density without destroying the specimen. The method of "decoration" by precipitation of copper on dislocations, introduced by Dash, and observation in infrared light are described in detail. Five causes for the occurrence of dislocations in growing crystals are discussed in detail: 1) As a consequence of plastic deformation. 2) As a consequence of a disc-shaped accumulation of vacancies in the crystal round the crystallization front, and their subsequent destruction under the formation of a dislocation loop. 3) As a consequence of impurity trapping. 4) As a consequence of the intergrowth of a dislocation from the inoculation. 5) As a consequence of fluctuations of the growth rate. Finally, the results of papers are

Card 2/3

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Dislocations in Semiconductor Crystals

S/053/60/072/003/003/004 B019/B056

discussed, which deal with the action of dislocations upon the characteristics of semiconductor instruments. It was found that for the production of instruments capable of withstanding a high inverse voltage, semiconductors with the lowest possible dislocation density must be used. There are 6 figures, 2 tables, and 81 references: 12 Soviet, 3 Japanese, 5 German, 2 British, 1 Dutch, 1 Italian, and 53 US.

S/564/61/003/000/013/029 D207/D304

AUTHORS:

Kokorish, Ye. Yu., and Myakinenkova, E. V.

TITLE:

On the problem of determining dislocation density by

chemical etching of germanium monocrystals

SOURCE:

Akademiya nauk SSSR. Institut kristallografii. Rost

kristallov, v. 3, 1961, 371, 379

TEXT: The authors determined dislocation densities on the surface of germanium monocrystals using four chemical etchants; the purpose of the work was to throw some light on the contradictions in published results. The etchants were: CP-4 (2 - 5 min. etching duration), potassium ferricyanide solution (8g  $K_3$ /Fe(CH)<sub>6</sub>/7, 12 g KOH, 100 cm<sup>3</sup> H<sub>2</sub>0; 1 - 5 min. in boiling solution); iodine solution (20 cm<sup>3</sup> HNO<sub>3</sub>, 16 cm<sup>3</sup> HF, 8 cm<sup>3</sup> CH<sub>3</sub>COOH, 0.3 mg I; 6 - 15 min. etching); and No. 2 solution (10 cm<sup>3</sup> HF, 10 cm<sup>3</sup> H<sub>2</sub>0<sub>2</sub>, 40 cm<sup>3</sup> H<sub>2</sub>0; 3 - 10 min. Card 1/3

On the problem ...

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etching) . Germanium was in the form of plates cut along (111) or (100) planes from a monocrystal at right angles to its growth axis. Before etching, the plates were ground with M-20 (M-20) powder, chemically polished in hot HF + HNO3 + H20 (5:5:1) solution for 10 - 15 sec., washed in doubly distilled water and dried. Etch pits were photographed at magnifications ranging from 120 to 450. Typical etch-pit densities for the same sample were (in cm 2): 9 x 10 for the ferricyanide etchant,  $6 \times 10^3$  for CP-4,  $3 \times 10^3$  in the iodine solution, and  $4 \times 10^3$  in the etchant No. 2. The highest density of dislocations was revealed by the ferricyanide etchant; it was nearly always equal to the sum of densities obtained with CP-4 and with the iodine etchant. It is suggested that the ferricyanide solution reveals edge, screw and mixed dislocations. The density of etch pits at mosaic block boundaries was the same in all the four etchants. Acknowledgments are made to N. N. Sheftal' for his advice and to V. K. Bichev for his help in experiments. There are 9 figures, 3 tables and 9 references: 2 Soviet-bloc and 7 non-Soviet-bloc. The 4

Card 2/3

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most recent references to the English-language publications read as follows: A. D. Kurtz, S. A. Kulin and B. L. Averbach, Phys. Rev., 101, 1285, 1956; J. Hornstra, J. Phys. a. Chem. Solids, 5, 129, 1958; W. Bardsley, R. L. Bell, B. W. Straughan, J. Electr. a. Control, 5, 19, 1958; R. G. Rhodes, K. O. Batsford, J. Electr. a. Control., 3, 403, 1957.

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S/564/61/003/000/015/029 D207/D304

AUTHORS:

Kokorish, Ye. Yu., and Sheftal!, N. N.

TITLE:

On the problem of growing germanium monocrystals free

of dislocations

SOURCE:

Akademiya namk SSSR. Institut kristallografii. Rost

kristallov, v. 3, 1961, 388-394

TEXT: The authors describe experiments carried out in 1957-58 on preparing germanium monocrystals free of dislocations. The purpose of the work was to obtain material from which better semiconductor devices could be made. A brief discussion of how dislocations are formed is followed by details of experimental procedure. Polycrystalline ingots of zone-purified germanium of > 30 ohm.cm resistivity were used as the raw material. Monocrystals were grown by Czochralski's technique of pulling from the melt in a hydrogen atmosphere. The rate of pulling was varied from 0.5 to 4 mm/min. A seed crystal was rotated at 50 - 100 rpm.

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Card 1/3

On the problem of ...

S/564/61/003/000/015/029 D207/D304

most recent references to the English-language publications read as follows: W. C. Dash, J. Appl. Phys., 29,736, 1958; P. Penning, Philips Res. Repts, 13, 79, 1958; F. D. Rosi, RCA Rev., 19, 349, 1958; J. G. Gressel, J. A. Powell, Progress in Semiconductors, II, 137, London, 1957.

Card 3/3

37967 8/137/62/000/005/058/150

A006/A101

AUTHOR:

Kokorish, Ye. Yu.

The effect of cooling conditions upon the formation of dislocations

in germanium crystals

Referativnyy zhurnal, Metallurgiya, no. 5, 1962, 38, abstract 50253 PERIODICAL:

(V sb. "Rost kristallov, v. 2", Moscow, AN SSSR, 1959, 120-125)

To investigate the distribution of dislocations along an.ingot, TEXT: several Ge single crystals of proper conductivity were grown by the method of pulling from the melt. Orientation of the primer was [111], pulling rate 1 mm/ min, the rotation rate of the crystal during its growth was 60 rpm. After drawing the ingots from them, perpendicularly to the growth axis at different distances from the primer, plates were cut to determine the density of dislocations. The plates were ground on glass with the aid of micropowder suspensions M-10 and M-14, in order to remove a layer of 70 -  $80\mu$ . After chemical polishing, the specimens were etched during 3 minutes in a boiling solution of 12 g KOH and 8 g K2 [Fe (CN)6] in 100 cm3 H20, with subsequent washing in distilled water and drying. The density of the etching pits is greater at the initial

Card 1/2

APPROVED FOR RELEASE: 06/19/2000 CIA-RDP86-00513R000723710010-0"

8/137/62/000/005/060/150 A006/A101

**AUTHORS:** 

Kokorish, Ye. Yu., Myakinenkova, E. V.

TITLE:

On the problem of determining the density of dislocations in germanium single crystals by chemical etching

PERIODICAL:

Referativnyy zhurnal, Metallurgiya, no. 5, 1962, 39-40, abstract 50260 (V sb. "Rost kristallov, v. 3", Moscow, AN SSSR, 1961, 371-379,

Diskus. 501-502)

A comparison was made of the density of etching pits, revealed with different etching agents on the same specimens along the crystal. The shape and different etching agents on the same specimens along the crystal. The shape and dimensions of the etching pits were determined. The following etching agents were used: 1) CP-4 (SR-4) composed of HNO3 (25 cm<sup>3</sup>) + HF (15 cm<sup>3</sup>) + CH3COOH (15 cm<sup>3</sup>) + Br; etching time was 2-5 min; 2) ferrous cyanide composed of K3 [Fe(CH)6](8g) + KOH (12 g) + H2O (100 cm<sup>3</sup>) with 1 - 5 min etching time in a boiling solution; 3) iodine composed of HNO3 (20 cm<sup>3</sup>) HF (16 cm<sup>3</sup>) + CH3COOH (8 cm<sup>3</sup>) + I (0.3 mg) with 6 - 15 min etching time and 4) No. 2, composed of HF (10 cm<sup>3</sup>) + H<sub>2</sub>O<sub>2</sub> (10 cm<sup>3</sup>) + H<sub>2</sub>O (40 cm<sup>3</sup>) with 3 - 10 min etching time. Prior to etching the specimen surface was ground on glass with micropowder M-2O. to etching, the specimen surface was ground on glass with micropowder M-20,